Silicon Photonic Design Iteation

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Schow Group

RadLink: Radiation Hard, High Bandwidth Optical Fiber Links for Detectors at High Energy Colliders

- Wavelength Division Multiplexing
 - Parallel readout on a single fiber
- External Optics
 - Lower mass, power, and complexity





Improving Spectral Bandwidth



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What's capable with SiPh Readout Chips

- Immediate Future Swap VCSELs
 - A direct stand in for current VCSELs in Verstaile Link+
 - 4 fibers x 10.24 Gbps \rightarrow 4 lambda x 10.24 Gbps
 - No mass/bandwidth improvements just more radiation hardness
- Soon WDM serialization
 - 8 lambda x 1.28 Gbps = 10.24 Gbps optical
 - Currently done using digital electronics
 - Single chip can fit >8 WDM sites so one chips handles 2x Versatile Link +
- Far Off Direct Optical Readout
 - SiPh modulators can operate at 50 Gbps
 - No triggering or digital electronic
 - Delivery of 50 Gbps signals requires tight integration
 - And a complete sensor redesign



RRM Electro-Optic Conversion



RRM Layout and Design







PIC Submissions GlobalFoundries 45CLO Silicon Photonics

Run #1 – Designed Aug 2021 – Arrived Feb 2022

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- Single nominal PN RRM with UID (Unintentionally Intrinsically Doped)
- Single highly doped PN RRM
- 4 channel WDM (3x nominal PN and 1x PN w/ UID)







Run #2 – Designed Feb 2022 – Arrived Sep 2022

- Lots of PiN junctions for forward bias
 - Not as promising or worth it as initially expected
- 6 um PN junction







Run #3 – Designed Aug 2022 – Arriving May 2023

- 4 Channel HD WDM w/ edge couplers
- 1.8mm TW-MZM with HD junction & edge couplers
- Single RRM w/ HD junction
 - {150, 175, 200, 225, 250} nm coupling gaps
 - {0, 5, 10, 15, 20} concentric coupling angles
 - All have undercut trench heaters
- PN junction AMZIs w/ abrupt junction
 - 100 um and 300um
 - HD and nominal
- 101 ring oscillator test site



Run #4 – Designed Feb 2023 – Arriving Oct 2023

- 10 Channel WDM site
 - 8 standalone rings
 - 7 w/ undercut trench, one w/o
 - 2 drivers
 - 1 Inverter based (for cryo applications)
 - 1 common source NMOS onlyRing oscille
 - 16 transistor flavors





10 Channel WDM

• 200 GHz spacing = 1.2 nm





Radiation Hardness – Total Ionizing Dose Previous Results



Run #1 Nominal PN Ring Design Error



Fine: CH 1,2,4 WDM and standalone highly doped PN

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Impacted: CH 3 WDM and standalone nominal PN

Impact to Device Performance



Nominally Nominally Highly Doped Doped (i) Doped Nominally Doped IVs up to 17.3563 MRad Highly Doped IVs up to 25.4991 MRad -2 r -2 Г -4 Looks like more like -4 Current [log(A)] **PIN than HD-PN** Current [log(A)] 01- 8- 9-05-Proper nominal PN junction yet to be tested – past nominal irradiated devices had extra i gap -12 -12 -14 -14 -2 0 2 -6 -4 -2 0 2 -6 -8 -4 Voltage [V] Voltage [V] p** n⁺ n⁺⁺ p^+ n+ n++ b₁ р n n+ n++ p** p^+ р n 17 BARBARA

Impact on Radiation Hardness

Optical Results – Highly Doped

- DC biased at -2 V during irradiation
- For simulated 2 Vpp input signal



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Extinction Ratio



Upcoming Work

- Abrupt nominal PN junction
 - How does it compare to PiN and highly doped
- Thermal phase shifters
 - Do they have TID impacts?
 - Can they help anneal damage?
- Optical measurements
 - Upgrades to X-ray cabinet
 - Future fiber connected devices (May)
- RD53 integration
 - Board design with 4 display inputs to 4 RRM channels

